



# **Sample Environment JRA-Meeting**

## **Progress Report October 2012**

**Dirk Wallacher**



**JRA-Sample Environment Meeting**  
**Berlin (HZB)**  
22nd October 2012



## Sample Environment JRA-Meeting

### Task 21.4: Development of Gas Adsorption Control Systems for Neutron Scattering Instruments

The measurement of hydrogen storage materials, as well as the characterisation of chemical and catalyst reactions in porous materials, is of significant interest. All facilities have some capability to work in this area but the aim of this task is to significantly extend this to allow real-time in-situ measurements of many diverse chemical and physical phenomena.

We plan to start by developing a **volumetric low pressure (<1.5 bar) gas adsorption measurement system** for experiments in an **Orange cryofurnace (1.5-600 K)** and, alternatively, in a **cryogen-free miniature pulse tube refrigerator (50-600 K)**. These systems will then be enhanced by further developments to extend the temperature and **pressure ranges up to 300 bar at 200°C**. The gas control systems will also be increased to provide **mass spectroscopy** and **constant pressure and flow conditions**. Finally, a system with a magnetic **gravimetric system** with a pressure range up to **100 bar** and a temperature range up to **500°C** will also be delivered.

## Deliverables

### Task 21.4: Development of Gas Adsorption Control Systems for Neutron Scattering Instruments

*D 21.2.2.2 Commissioning of HMI 10 kbar H<sub>2</sub> handling system (12)*

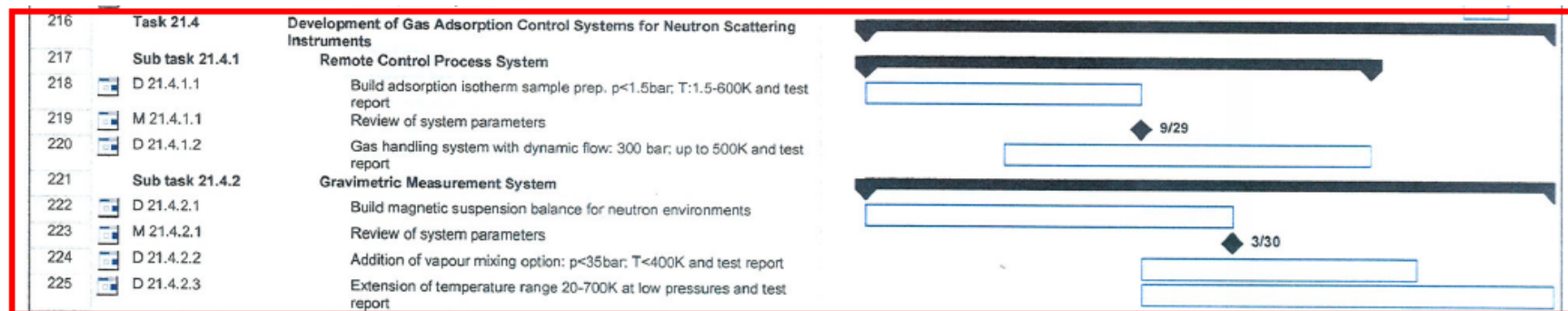
D 21.4.1.1 Build adsorption isotherm sample prep.  $p < 1.5\text{bar}$ ;  $T: 1.5\text{-}600\text{K}$  (21)

D 21.4.1.2 Gas handling system with dynamic flow: 300 bar; up to 500K (36)

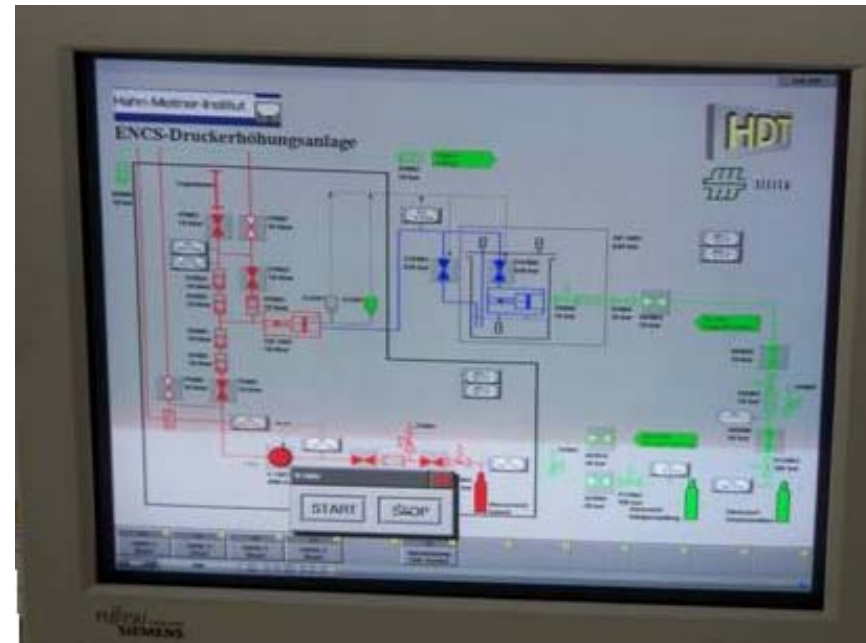
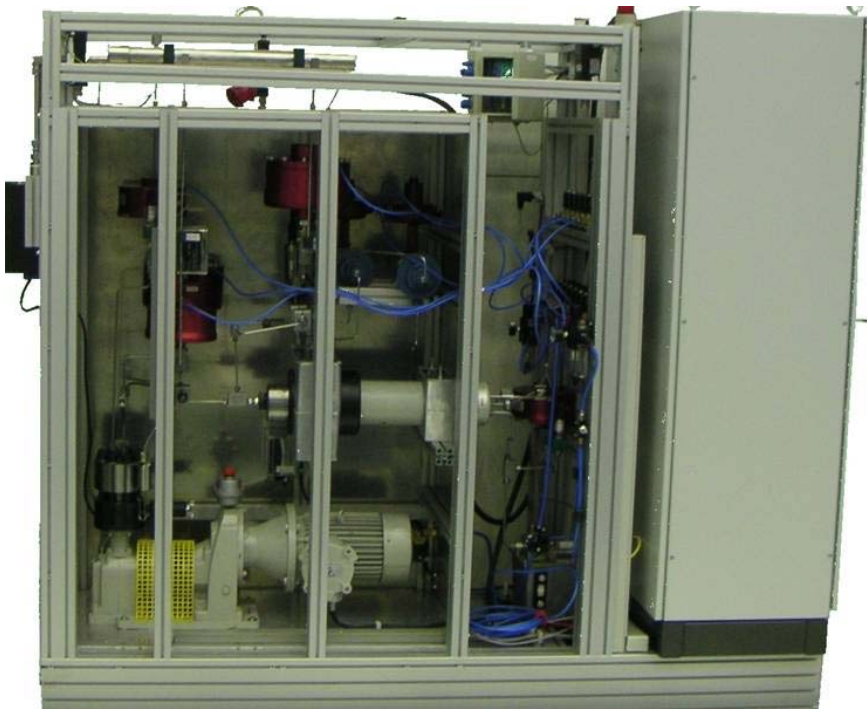
D 21.4.2.1 Build magnetic suspension balance for neutron environments (27)

D 21.4.2.2 Addition of vapour mixing option:  $p < 35\text{bar}$ ;  $T < 400\text{K}$  (39)

D 21.4.2.3 Extension of temperature range 20-700K at low pressures (48)

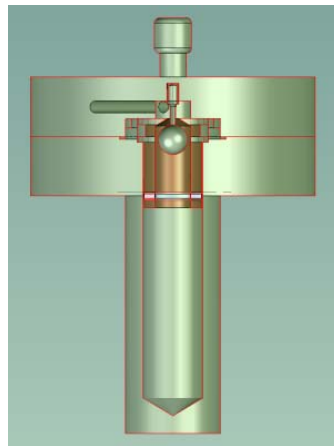


## *D 21.2.2.2 Commissioning of HMI 10 kbar H<sub>2</sub> handling system*



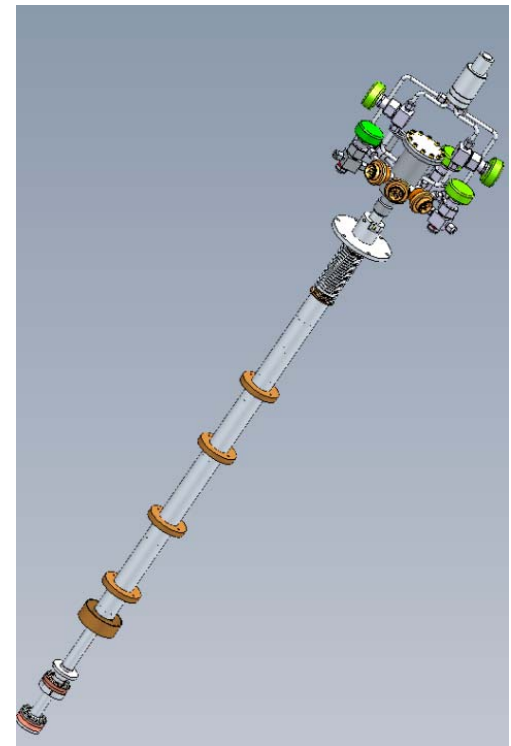
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### OF-Adsorption-Stick (1.5K - 600K, 300bar) with Al- sample cells



$d_a$ (mm)	300 K	400 K	500 K	600K	
12	300 bar	100 bar	10 bar		1 bar
14	300 bar	200 bar	50 bar		20 bar
20	300 bar	300 bar	300 bar		300 bar

Improved design by ILL





## Cyrogenfree Sorption Systems (10K – 600K)

### Mini-Pulsetube



### Gifford-McMahon

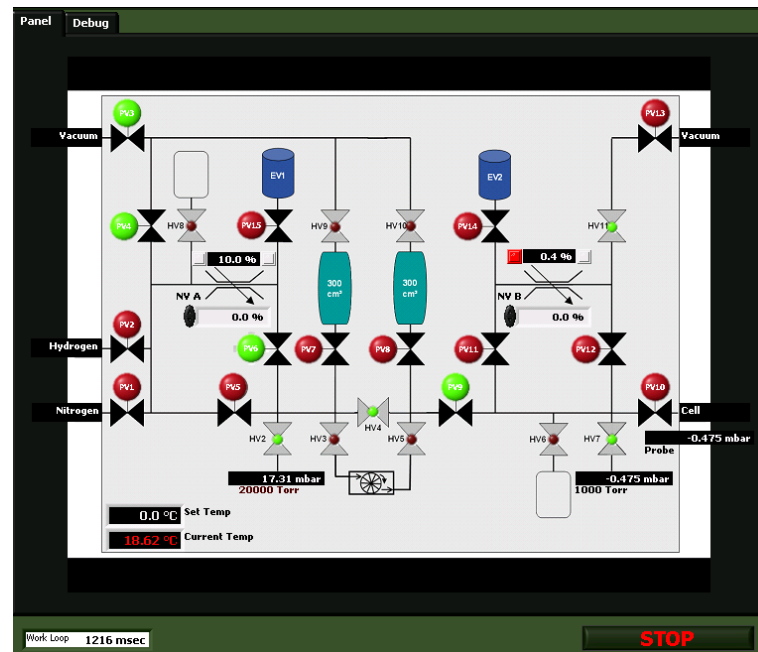


High temperature  
stage 800K

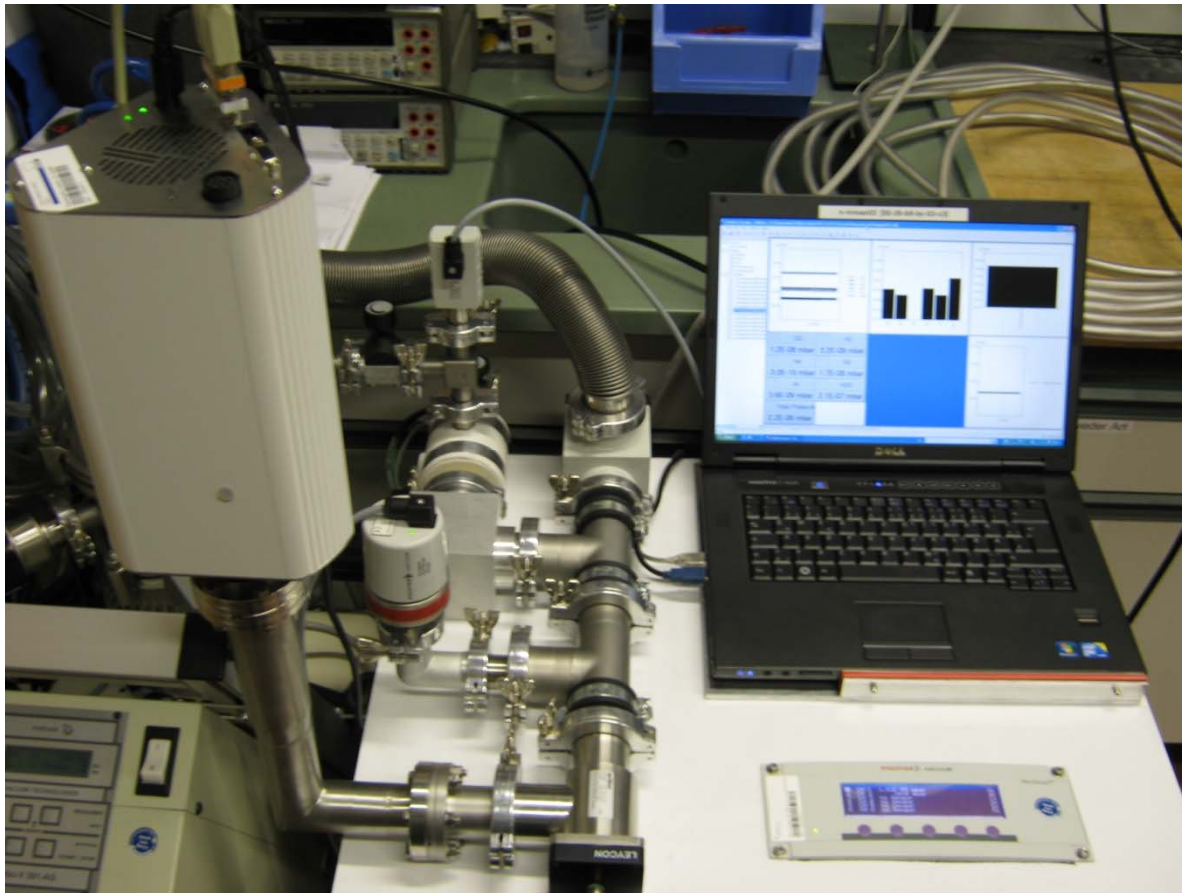


## D 21.4.1.2 Gas handling system with dynamic flow: 300 bar; up to 500K

(in user service since August'12)

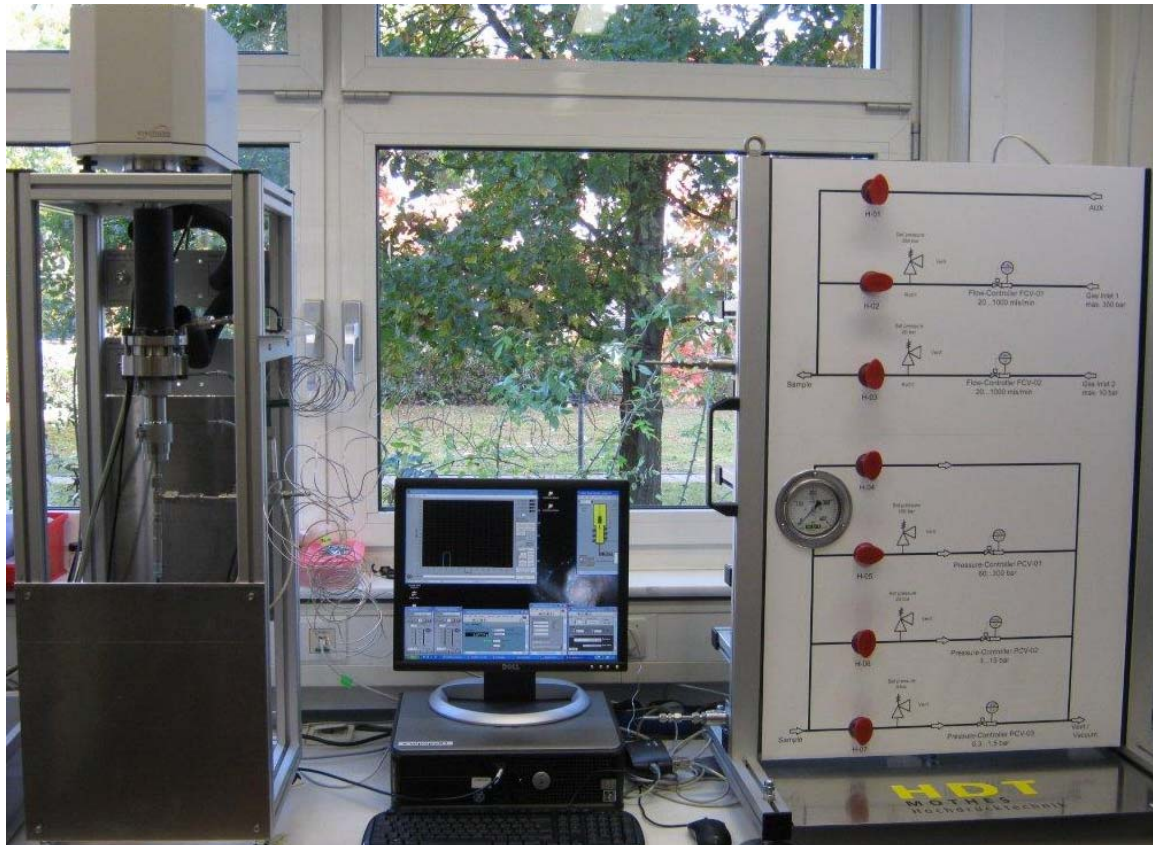


## Residual gas analysis station

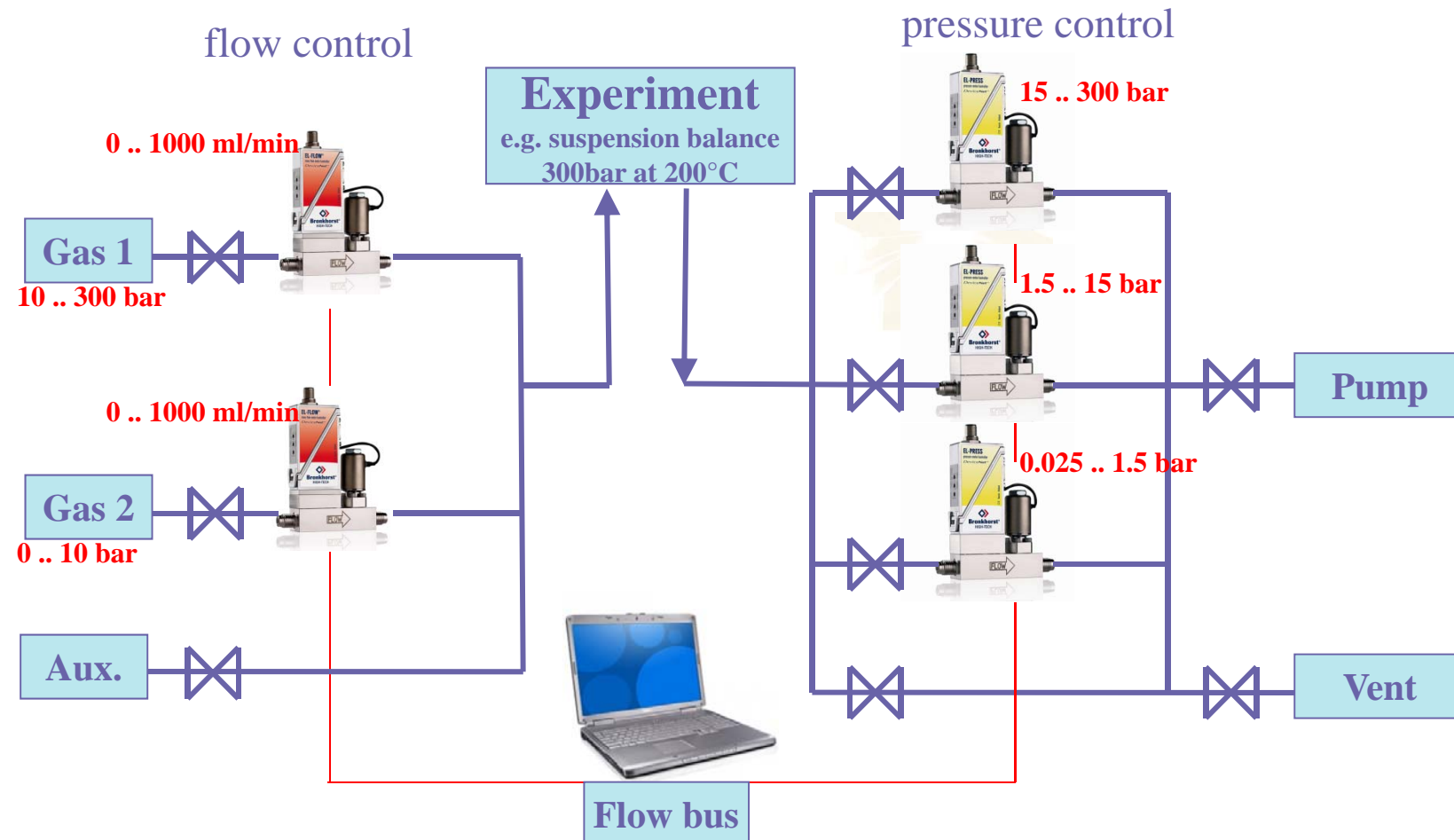




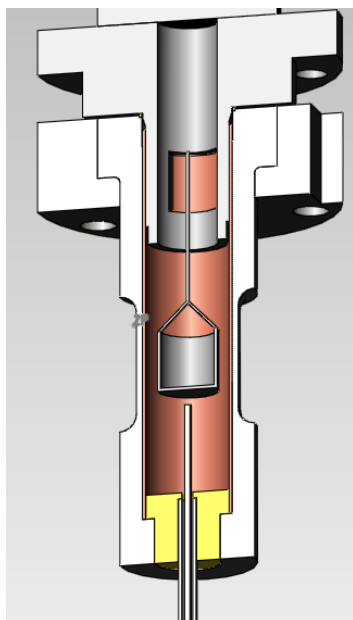
## D 21.4.2.2 Addition of vapour mixing option: $p < 35 \text{ bar}$ ; $T < 400 \text{ K}$



## Gas handling system 300 bar – continuous flow improved pressure and flow control at ambient temperatures



## D 21.4.1.1 Build adsorption isotherm sample prep. $p < 1.5 \text{ bar}$ ; $T: 1.5\text{-}600 \text{ K}$



- $T = 500 \text{ C} / P = 100 \text{ bars}$
- $T = 200 \text{ C} / P = 300 \text{ bars}$
- hydrogen resistant

High Pressure/temperature Cell

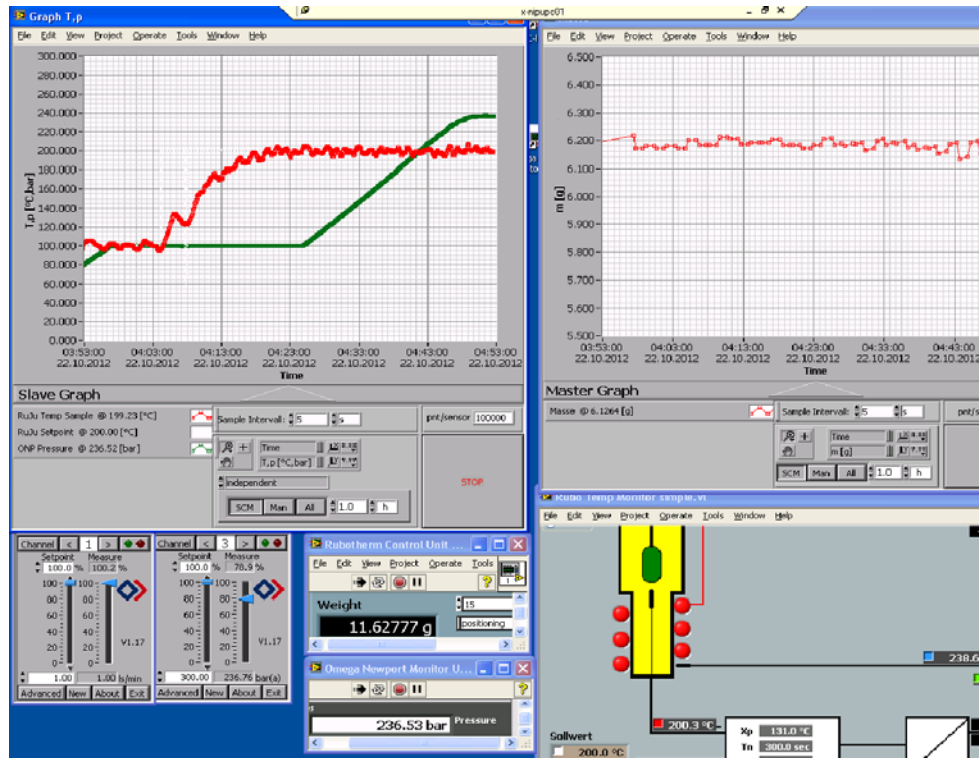


Humidity Option

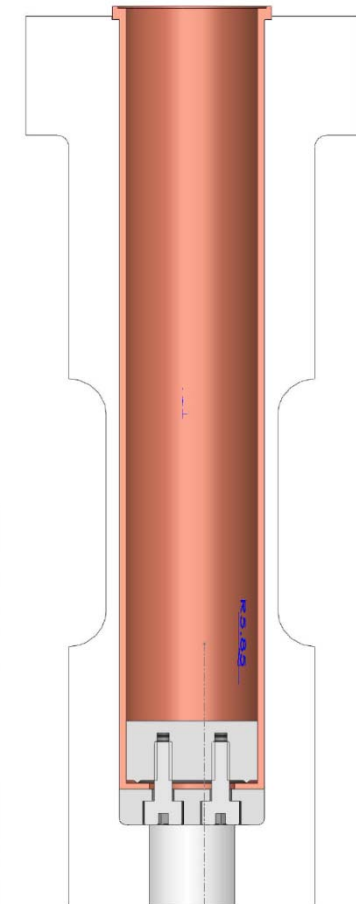




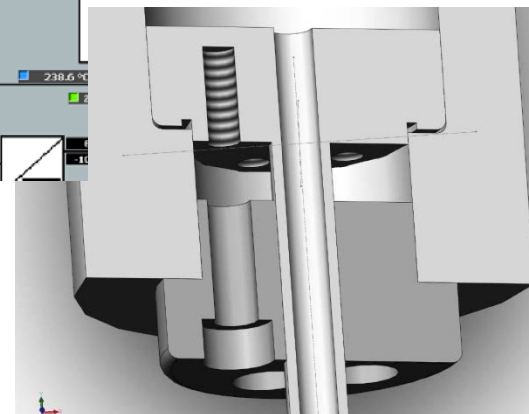
## First Tests: Leakage at 240 bar / 200°C



## H2-Protection-Liner

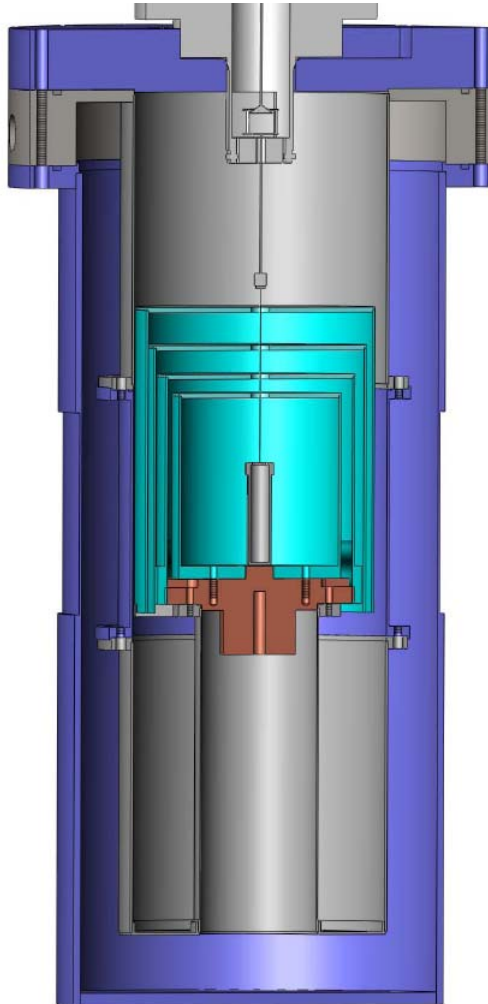



## Inert gas Seal





## D 21.4.2.3 Extension of temperature range 20-700K at low pressures



- Design finished
  - Parts under ordered
  - Assembly under construction
- 
- A small, stylized sun icon with yellow rays, positioned to the right of the text 'Scheduled for end of November'12'.
- Scheduled for end of November'12

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Outstanding parts:

- Report gashandling
- Sealing and testing of HTP-option for balance
- Low temperature expansion balance



**Thanks for your attention**

**and**

**Nico Grimm**